## **EUROPEAN PATENT OFFICE**

## Patent Abstracts of Japan



**PUBLICATION NUMBER** 

2000138334

**PUBLICATION DATE** 

16-05-00

**APPLICATION DATE** 

11-11-97

APPLICATION NUMBER

11346757

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INT.CL.

H01L 23/48 B23K 35/26 H01B 5/02

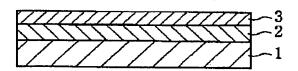
H01L 23/50

TITLE

**OUTER LEAD PART OF LEAD FRAME** 

MATERIAL AND SEMICONDUCTOR DEVICE USING THE OUTER LEAD

**PART** 



ABSTRACT :

PROBLEM TO BE SOLVED: To provide an outer lead part, which does adversely effect the environment, is superior in solderability and in welding strength at welding and is small in an ununiform section which is formed on the outer lead part at the time of a reflow treatment, of a lead frame material.

SOLUTION: This outer lead part A is one formed by laminating a first t1 thick plated layer 2 consisting of an Sn single member and a second t2 thick plated layer 1 consisting of an Si alloy containing at least one kind of a metal chosen from a group consisting of Ag, Bi, Cu, In and Zn in the order of these layers 2 and 1 on the surface of a conductive base body 3 and the t1 and the t2 are values to satisfy the conditions of 6 µm≤t1≤10 µm. 1  $\mu m \le t \le 3 \mu m$  and  $0.1 \le t \le t \le 1 \le 0.5$ .

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